

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

Masataka TAMURA et al.

Title:

UNDERWATER LASER

PROCESSING APPARATUS AND UNDERWATER LASER

PROCESSING METHOD

Appl. No.:

10/763,336

Filing Date:

1/26/2004

Examiner:

Maria Alexandra ELVE

Art Unit:

1793

Confirmation

6946

Number:

## AMENDMENT AND REPLY ACCOMPANYING RCE

Mail Stop RCE Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

This communication is responsive to the Final Office Action dated March 17, 2008, concerning the above-referenced patent application.

A petition for extension of time is submitted herewith making this response timely.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this document.

Remarks/Arguments begin on page 4 of this document.

Please amend the application as follows:

09/18/2008 HAHMED1 00000033 10763336

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